

1 **SYNTHESIS OF MOLECULAR SIEVES BY HYDROTHERMAL**
2 **TREATMENT WITH ACID**

3
4 This application claims the benefit of U. S. Provisional Application No.
5 60/257,503, filed December 22, 2000.

6
7 **BACKGROUND OF THE INVENTION**

8
9 Hydrophobic, pure-silica zeolites are useful materials primarily because
10 of their organophylic character and thermal and hydrothermal stability.

11 Microporous, pure-silica molecular sieves can be synthesized hydrothermally
12 using organic molecules - structure-directing agents (SDAs) – to kinetically
13 steer their syntheses to the desired products. However, in many cases, the
14 presence (or absence) of tetrahedral, non-silicon atoms in the synthesis such
15 as boron, aluminum, or zinc causes the formation of different crystalline
16 phases or prevents the formation of a crystalline phase entirely. For example,
17 the use of the N,N,N-trimethyl-2-adamantanammonium cation as an SDA
18 gives SSZ-24 (AFI) when boron is included in the synthesis gel, and SSZ-13,
19 SSZ-23 or SSZ-25 when varying amounts of aluminum are included in the
20 synthesis. In the absence of any tetrahedral, non-silicon atom in the
21 synthesis, no crystalline products are formed. Situations like this invariably
22 arise in zeolite synthesis and as a result, many framework topologies can only
23 be synthesized in a narrow range of framework compositions. For example,
24 molecular sieves of the CON topology have only been directly synthesized to
25 date as borosilicates (SSZ-33, CIT-1) or as an aluminosilicate (SSZ-26).

26 To access other framework compositions, various strategies have been
27 employed. Dealumination of zeolites is commonly carried out to synthesize
28 high-silica or pure-silica zeolites. Many dealumination procedures have been
29 developed over the years including steaming, treatment with mineral acids or
30 chelating agents, reaction with silicon tetrachloride and treatment with silicon
31 hexafluoride.

32 Another route to both all-silica and heteroatom-containing framework
33 compositions is through the use of borosilicates as precursor species.

1 Removal of boron from the framework of molecular sieves requires
2 significantly milder conditions than does the removal of aluminum. Vacancies
3 with tetrahedral coordination can then be repopulated in a subsequent step
4 with a variety of species including silicon, titanium, and aluminum, among
5 others.

6 Recently, the zincosilicate CIT-6 (*BEA topology) was synthesized and
7 extensively characterized. This material is unique because it can be used as a
8 precursor to a variety of molecular sieves of the *BEA structure. The organic
9 SDA can be removed from the micropores by solvent extraction techniques.
10 Furthermore, zinc, like boron, can be easily removed from the molecular sieve
11 framework under relatively mild conditions. In particular, aqueous acetic acid
12 treatments were found to be suitable for removal of zinc from the framework
13 of CIT-6 while simultaneously removing the organic SDA from the micropores.
14 Under the proper conditions, zinc can be completely removed from the
15 material and the vacancies (defects) left behind can be healed with silicon that
16 is presumably dissolved from other parts of the crystal. Similarly, in the
17 development of organic-functionalized molecular sieves (OFMSs), we found
18 that extraction of the organic SDA from the micropores of the molecular sieve
19 using aqueous acetic acid resulted in materials that were essentially free of
20 structural defects¹⁴. In contrast, extraction with other solvents left a material
21 that contained a significant number of internal defects as determined by ²⁹Si
22 solid state NMR spectroscopy.

23 The present invention relates to the use of acid treatment to a variety of
24 calcined molecular sieves with different framework compositions and
25 structures and the generality of this methodology for preparing a broad
26 spectrum of molecular sieve materials. Calcined borosilicate and pure-silica
27 molecular sieves of different topologies are treated with acid under a variety of
28 conditions and are subsequently characterized in detail. Specific attention is
29 paid to the role of acetic acid in this system.

30

SUMMARY OF THE INVENTION

In accordance with the present invention there is provided a method of treating a molecular sieve containing a structure directing agent, the method comprising the steps of:

A. heating the structure directing agent-containing molecular sieve to a temperature and for a time sufficient to remove the structure directing agent from the molecular sieve; and

B. heating the molecular sieve from step A in an aqueous, acidic medium.

The invention also includes the wherein the heating in step A is calcination.

The aqueous, acidic medium may be an aqueous solution of an organic acid or a mineral acid. The organic acid may be acetic acid, propionic acid or oxalic acid. The mineral acid may be hydrochloric acid, nitric acid, sulfuric acid or phosphoric acid.

The aqueous, acid medium has a pH below the isoelectric point of silica, preferably a pH of greater than 0 to about 2.5.

In accordance with the present invention, the aqueous, acid medium in step B is heated at a temperature of about 135°C. or about 160°C to about 185°C.

In accordance with this invention, the molecular sieve is preferably a zeolite. The zeolite may have the CON, MWW, MFI or *BEA crystal topology. The zeolite preferably contains silicon and may contain silicon and aluminum.

Further provided in accordance with the present invention is a method of increasing the hydrophobicity of a molecular sieve containing a structure directing agent, the method comprising the steps of:

A. heating the structure directing agent-containing molecular sieve to a temperature and for a time sufficient to remove the structure directing agent from the molecular sieve; and

B. heating the molecular sieve from step A in an aqueous, acidic medium

wherein the molecular sieve from step B is more hydrophobic than the molecular sieve used in step A.

1 The present invention also provides a molecular sieve produced by the
2 process comprising the steps of:

- 3 A. heating a structure directing agent-containing molecular sieve to
4 a temperature and for a time sufficient to remove the structure
5 directing agent from the molecular sieve; and
6 B. heating the molecular sieve from step A in an aqueous, acidic
7 medium.

8
9 DETAILED DESCRIPTION OF THE INVENTION

10
11 **Molecular sieve synthesis.** Borosilicate CIT-1 (CON topology) was
12 synthesized via the procedure described in Lobo, R. F. and Davis, M. E., *J.*
13 *Am. Chem. Soc.* 1995, 117, 3764 using N,N,N-trimethyl(+)myrtanilammonium
14 hydroxide as an SDA in a Teflon-lined autoclave at 160°C. Borosilicate SSZ-
15 33 (CON topology) was synthesized as described in U. S. Patent No.
16 4,963,337, issued October 16, 1990 to Zones. The borosilicate of the MWW
17 topology, ERB-1, was prepared using the procedure described in Millini, R.,
18 Perego, G., Parker, W. O., Bellussi, G. and Carluccio, L. *Microporous*
19 *Materials* 1995, 4, 221. Aluminum-free, boron-containing ZSM-5 (MFI
20 topology) was synthesized using the procedure reported in Dwyer, J. and
21 Zhao, J. *J. Mater. Chem.* 1992, 2, 235. Silicalite, the all-silica variant of ZSM-
22 5, was synthesized in the absence of alkali metal ions using a mixture of
23 tetrapropylammonium bromide and piperazine as SDAs. Molecular sieves with
24 the *BEA topology were synthesized in a variety of forms. Borosilicate and
25 pure-silica beta molecular sieves were synthesized using tetraethylammonium
26 fluoride as the SDA. These samples are denoted as B-Beta-F and Si-Beta-F,
27 respectively. Pure-silica beta was also synthesized using 4,4'-
28 trimethylenebis(1-methyl-1-benzylpiperidinium) hydroxide as an SDA using
29 the procedure described in Tsuji, K. and Davis, M. E. *Microporous Mater.*
30 1997, 11, 53. This material is denoted as Si-Beta-OH. A borosilicate beta
31 sample, referred to as B-Beta-OH, was also synthesized in hydroxide media
32 following the procedure described in U. S. Patent No. 5,187,132, issued
33 February 16, 1993 to Zones et al. All materials were calcined to remove the
34 occluded structure-directing agent. Samples were heated in an oven at

1 approximately 2°C/min in a nitrogen purge up to the maximum temperature of
2 500-675°C at which point air was fed to the oven for 4-8 hours.

3 The molecular sieves treated in accordance with this invention
4 preferably contain silicon. They may also contain silicon and aluminum.
5 Preferred molecular sieves are zeolites.

6
7 **Acetic acid treatment.** For experiments at temperatures above 100°C,
8 calcined molecular sieves were treated in Teflon-lined autoclaves in an oven
9 with rotation at ~60 rpm for 6 days unless noted. In a typical experiment, 0.2
10 g of molecular sieve was added to a 45 mL autoclave filled with 25 g water
11 and 10 g glacial acetic acid (pH ~ 1.65). After 144 hours of heating, the
12 autoclave was cooled rapidly in a water bath and the solid products were
13 washed extensively with water and acetone and recovered by filtration. Any
14 variations on this scheme are noted specifically below.

15 Acetic acid is used throughout this specification as an example of a
16 suitable acid. Other organic acids and mineral acids may also be used.
17 Examples of other organic acids include, but are not limited to, propionic acid
18 and oxalic acid. Examples of mineral acids include hydrochloric acid, nitric
19 acid, sulfuric acid and phosphoric acid.

20
21 **Analysis.** X-ray powder diffraction (XRD) patterns were collected on a
22 Scintag XDS 2000 diffractometer using Cu-K radiation. ^{11}B , ^{27}Al and ^{29}Si
23 NMR spectra were recorded on a Bruker AM 300 spectrometer equipped with
24 a cross-polarization (CP) magic-angle spinning (MAS) accessory. Samples
25 were packed in zirconia rotors (7mm - ^{29}Si ; 4mm - ^{11}B , ^{27}Al) and spun in air.
26 The ^{29}Si (59.63 MHz) NMR spectra were obtained at a spinning speed of 4
27 kHz, with recycle delays of 10 s for Bloch decay (BD) experiments and 2-5
28 seconds for CP experiments. Contact times for CP experiments were varied
29 from 2.5-4.5 ms. The ^{27}Al (78.2 MHz) and ^{11}B spectra (96.3 MHz) were
30 obtained at a spinning speed of 12 kHz (using fully hydrated samples in the
31 case of Al). Additional ^{29}Si (99.38 MHz) BD and CP NMR experiments were
32 carried out on a Bruker DSX500. In this case, a spinning speed of 8 kHz was
33 used with 4mm rotors. The DSX 500 was also used for ^{71}Ga (152.48 MHz)

1 BD NMR experiments with a spinning speed of 12 KHz. In all cases,
2 experiments were referenced externally (B: aq. Boric acid = 18.8 ppm; Al: 1N
3 Al(NO₃)₃; Si: tetrakisdimethylsilane; Ga: 1N Ga(NO₃)₃). All reported ²⁹Si NMR
4 results are from the 300 MHz instrument unless specifically noted. Field-
5 emission scanning electron microscopy (FE-SEM) was performed using a
6 Hitachi S-900 at the University of Tokyo. Prior to observation, the samples
7 were dried in an oven at 85 °C, and coated by Pt for a few seconds using
8 magnetron sputtering (Hitachi, E-1030). The acceleration voltage for the
9 observation was varied between 7 and 10 kV. Nitrogen adsorption isotherms
10 were obtained at 77K using an Omnisorp 100 sorption apparatus operating in
11 static mode using fixed dosing. Prior to the adsorption experiment, samples
12 were treated under vacuum at 175°C for at least 6 hours. Vapor phase water
13 adsorption isotherms were obtained on a McBain-Baker balance after
14 pretreatment at 175-200°C in-situ. Nitrogen and water adsorption capacities
15 are reported at P/Po = 0.05 and P/Po = 0.2, respectively. Elemental analyses
16 were performed at Galbraith Laboratories, Inc., Knoxville Tennessee.

17
18 **Structural Characterization.** All of the samples used are highly crystalline,
19 as determined by XRD and nitrogen physisorption analysis. In most cases,
20 the acetic acid treatment results in no notable changes in the XRD patterns of
21 the samples. Exceptions are the XRD patterns of ERB-1 which show an
22 additional peak at 2θ = 3.5 in samples extracted under all conditions. This
23 extra intensity is also seen in other all-silica materials with the MWW topology.

24 In contrast to the XRD results, ²⁹Si BD NMR results show significant
25 differences between the calcined and acetic acid treated molecular sieves in
26 most cases. As the temperature of the treatment is increased, the amount of
27 Q³ silicon in the sample decreases relative to Q⁴ silicon. In addition, there is
28 a significant sharpening of the Q⁴ region, allowing crystallographically distinct
29 T sites to be distinguished. These highly resolved NMR spectra can only
30 result from expulsion of boron from the lattice and healing of the created
31 framework defects with silicon. This loss of boron is confirmed by elemental
32 analysis (Table 1). CIT-1, another borosilicate of the CON topology, behaves
33 similarly. However, in this case, the most highly resolved NMR spectra
34 appear slightly different from those of SSZ-33, likely due to the fact that SSZ-

1 33 is an intergrowth of two polymorphs while CIT-1 is a single polymorph.
 2 High silica samples of SSZ-33 and CIT-1 that are nearly free of defects have
 3 not been obtained previously. Reported attempts to produce materials of this
 4 nature by steaming were unsuccessful.

5 The ^{29}Si BD NMR spectra of CIT-1 treated with acetic acid show at
 6 least five readily identifiable Q^4 silicon maxima at -109.35 , -111.15 , -111.95 , $-$
 7 112.95 , and -116.2 ppm. As there are seven crystallographically unique
 8 tetrahedral sites in the CON topology³, further deconvolution of the spectra
 9 are required in order to identify all the sites.

10 The ^{29}Si BD NMR spectra of ERB-1 (MWW topology) treated with acid
 11 after calcination are also markedly affected by the treatment conditions. Like
 12 the molecular sieves of the CON topology, treatment at higher temperatures
 13 yields materials with NMR spectra exhibiting fewer structural defects (Q^3
 14 silicon) and increased T-site resolution in the Q^4 region. The spectra of the
 15 acetic acid treated materials agree quite well with the published spectrum of
 16 ITQ-1, a silicate of the same MWW topology. This result indicates that the
 17 present method is effective on materials that contain only 10 MR pore
 18 openings (MWW has also 12 MR pores that do not open to the exterior of the
 19 crystal) in addition to the CON materials that have 10 and 12 MR pore
 20 openings. Furthermore, the fact that the technique works on a material with a
 21 relatively high boron content (see Table 1) illustrates its versatility. While the
 22 ^{29}Si BD NMR spectra of the acetic acid treated materials exhibit essentially no
 23 Q^3 silicon, the materials are not perfectly defect-free, as evidenced by the ^{29}Si
 24 CP NMR spectra shown in Figure 6.

25 Expulsion of boron from the lattice and healing of defects with silicon
 26 has an effect on the sorptive properties of the molecular sieves. In most
 27 cases, a minor loss in the nitrogen adsorption capacity is observed for the
 28 samples treated with acid after calcination, as shown in the data listed in
 29 Table 1. The silicon that heals the defect sites in the deboronated samples
 30 must originate from some portion of the sample, as no extra silicon source is
 31 included in the procedure. This slight loss in porosity is likely due to some
 32 dissolution of the crystal. FE-SEM results do not show many significant
 33 changes in crystal morphology after treatment with acetic acid. For the cases
 34 of SSZ-33 and ERB-1, many different crystal habits are evident, with sizes

1 ranging from tens of nanometers to several microns. After treatment at
2 various temperatures with aqueous acid after calcination, the FE-SEM images
3 of the materials are virtually unchanged with regard to particle morphology.
4 However, when the materials are treated in a manner that results in solids
5 where nearly all of their defects are healed as judged by ^{29}Si BD NMR,
6 notable changes in surface features are apparent in some of the FE-SEM
7 images. For the SSZ-33 samples where the defects have been healed,
8 triangular mesopores are evident in the samples. The number of mesopores
9 appears to be larger on samples treated at the higher temperature. Very
10 small particles are visible on the surface of the crystals that are not present in
11 the other images. These particles may result from dissolution of the small
12 spherical particles in the sample. Another possibility is that they originate
13 from silica that was previously part of the large crystals in the locations of the
14 mesopores.

15 The presence of the mesopores is important for two reasons. First, it
16 indicates that the silica required to heal the defect sites of the materials may
17 come from the crystal itself, rather than from the smaller particles present via
18 an Ostwald's ripening mechanism. This observation, however, does not rule
19 out the possibility that the smaller crystals are dissolved in order to provide
20 silica that heals defects in the larger ones, although the relative abundances
21 of the small and large particles do not appear to change after treatment with
22 acetic acid. The second important implication of the presence of mesopores
23 concerns the transport of soluble silica species, as the presence of large
24 mesopores would greatly enhance the movement of these species through
25 the pores to the defect sites that they must heal. Note that although
26 mesopores are detected clearly by FE-SEM, significant differences in the
27 nitrogen physisorption isotherms of materials with and without mesopores
28 were not detected due to the low cut-off pressure of the experiments (200
29 Torr).

30 Another consequence of the expulsion of boron and healing the defects
31 with silicon is an increase in hydrophobicity. The data in Table 1 illustrate that
32 there is a significant decline in the water adsorption capacities of the materials
33 after calcination followed by treatment with acid, indicating increased
34 hydrophobicity resulting from replacement of boron with silicon in the lattice.

1 The hydrophobicity as measured by the water adsorption uptake correlates
 2 nicely with the population of Q^3 silicon as determined by ^{29}Si BD NMR (less
 3 Q^3 silicon = lower water adsorption). Furthermore, the hydrophobicities of the
 4 materials compare well with those of calcined, defect-free materials such as
 5 calcined, pure-silica beta synthesized in fluoride media ($<0.01 \text{ cc/g}^{14}$).

6 On some materials, the affect of the acid treatment is not as
 7 pronounced as illustrated above. For example, when calcined B-MFI is
 8 treated with aqueous acetic acid, boron is expelled from the framework but
 9 only a fraction of the defects are healed (from the ^{29}Si BD NMR spectra).
 10 Further evidence of the transformation from the borosilicate to the pure-
 11 silicate is the increased hydrophobicity of the treated material (Table 1) and
 12 the development of additional uptake in the nitrogen physisorption experiment
 13 due to nitrogen restructuring. This restructuring is well-known in pure-silica
 14 MFI materials but uncommon in heteroatom-containing MFI samples. Of note
 15 is the fact that the value of P/P_o at which the nitrogen restructuring occurs in
 16 the isotherm of the acetic acid treated B-MFI ($P/P_o = 0.05-0.07$) differs from
 17 that of Si-MFI ($P/P_o = 0.15-0.18$). This may be due to differences in crystal
 18 morphology or due to difference in the number of internal defects (polar
 19 adsorption sites can affect the dipolar interactions in nitrogen) in each sample.

20 All-silica MFI (Si-MFI) was also treated with acid solution after
 21 calcination in an effort to heal anionic defects originating from the charge
 22 balancing tetrapropylammonium ion (TPA) in the hydroxide mediated
 23 synthesis (see Flanigan, E. M., Bennett, J. M. Grose, R. W., Cohen, J. P.,
 24 Patton, R. L., Kirchner, R. M. and Smith, J. V. *Nature* 1978, 271, 512). In this
 25 case, the ^{29}Si BD NMR spectrum sharpens to appear more like a defect-free,
 26 all-silica material synthesized in fluoride media, although some visible Q^3
 27 silicon species at -102.5 ppm clearly remain. The apparent lower efficiency
 28 of the treatment on molecular sieves with the MFI topology may be due to the
 29 small pore apertures that could limit migration of soluble silica species.

30 A series of molecular sieves with the *BEA structure were also
 31 subjected to calcination followed by the acid treatment. Si-Beta-OH, a
 32 nanocrystalline all-silica beta material, did not show significant increases in
 33 hydrophobicity (Table 1) after treatment with acetic acid solutions nor did it
 34 exhibit significantly less Q^3 silicon in the ^{29}Si BD NMR experiments, although

1 significant changes in nitrogen sorption capacities (Table 1) indicated
2 significant solid dissolution had taken place. Similarly, a nanocrystalline B-
3 Beta sample synthesized in hydroxide media also showed significant levels of
4 Q³ silicon in ²⁹Si BD NMR experiments. In contrast to the results obtained
5 with the nanocrystalline samples, a boron beta sample with significantly larger
6 crystals, B-Beta-F, could be successfully deboronated with healing of the
7 subsequent defect sites during aqueous acetic acid treatment. However, this
8 material was very sensitive to the temperature of the treatment. As
9 demonstrated by the nitrogen adsorption data in Table 1, extraction at lower
10 temperatures was useful for deboronating the molecular sieve and
11 maintaining good crystallinity whereas higher temperatures led to a significant
12 loss of porosity. Particularly noteworthy is the change in the ²⁹Si BD NMR
13 spectrum after treatment at 185°C, conditions that lead to significant structural
14 collapse. This loss in crystallinity can also be seen visually upon inspection of
15 the FE-SEM image of the 185°C treated material.

16 Numerous experiments were carried out on the SSZ-33 material to
17 ascertain information concerning the role of acetic acid and the mechanism of
18 defect repopulation. Samples were treated under a variety of conditions, with
19 temperature, pH, and the type of solution used as the major variables.
20 Descriptions of the various experiments and the characterization of the
21 resulting samples are tabulated in Table 3. Varying the nature of the acid
22 over a narrow range of pH (1.3-1.75) had little affect on the properties of the
23 resulting material. Use of an organic acid such as acetic acid or different
24 mineral acids that included nitric, sulfuric and hydrochloric all successfully
25 deboronated SSZ-33 and healed the resulting defects to a similar degree
26 (ascertained by the amount of Q³ silicon that is apparent in the ²⁹Si BD NMR
27 spectra). The mineral acids appear to give materials with slightly sharper Q⁴
28 regions in the ²⁹Si BD NMR spectra. In addition, treatment with mineral acids
29 results in materials with more significant porosity losses than treatment with
30 acetic acid. This may indicate that the mineral acids more readily solubilize
31 silica than does the organic acid. Similar results have been observed while
32 extracting TEAF from all-silica beta using both aqueous hydrochloric acid and
33 acetic acid at the same pH (pH=1.65, 80°C, 12 hrs, 2x). Both treatments
34 completely remove TEAF from the pores of the molecular sieve but the

1 mineral acid treatment results in significant formation of mesopores as
2 determined by nitrogen physisorption measurements.

3 Variations in the pH appear to have a significant affect on the resulting
4 properties of the solids. pH adjustment was carried out by increasing the
5 amount of acetic acid relative to water to achieve more acidic conditions or by
6 adding aqueous sodium hydroxide to the standard mixture of acetic acid and
7 water to achieve more basic conditions. At 135°C, the amount of Q³ silicon
8 decreases and the sharpness of the Q⁴ region increases upon moving from a
9 pH of 2.5 to 1.65. However, at a pH of 0.75, the results are generally poorer.
10 This is may be due to the high organic content of the treatment solution (60%
11 acetic acid) that may limit the solubility of dissolved silica species. For
12 treatment at 185°C, the low and moderate pHs gave hydrophobic materials
13 with well-resolved ²⁹Si BD NMR spectra. However, at a pH of 2.5, structural
14 degradation occurred and both the XRD powder pattern and nitrogen
15 adsorption results were indicative of a partially amorphous material.
16 Apparently, the presence of the added sodium used to adjust the pH of the
17 solution leads to loss of crystallinity at high temperatures. A similar result was
18 obtained upon treatment at a pH of 3.5.

19 The effect of acidic solutions on microporous metallosilicates,
20 especially aluminosilicates and borosilicates is well documented. Aqueous
21 acids are efficient hydrolyzing agents for the removal of boron and aluminum
22 from the framework, leaving behind silanol nests with Si-O(H) groups that are
23 positioned for the incorporation of other tetrahedral species such as titanium
24 or silicon. Lee, E. F. T. and Rees, L. V. C. *J. Chem. Soc. Faraday Trans.1*,
25 1987, 83, 1531 discloses the importance of pH during dealumination of zeolite
26 NaY with hydrochloric acid; dealumination did not occur above a pH of 2.3
27 and complete dealumination occurred below a pH of 0.46. Apelian, M. R.,
28 Fung, A. S., Kennedy, G. J. and Degnan, T. F. *J. Phys. Chem.*, 1996, 100,
29 16577 characterizes in detail zeolite beta samples that were dealuminated by
30 aqueous oxalic acid treatments. They showed using FTIR spectroscopy that
31 samples dealuminated for extended periods of time with the di-acid solution
32 (pH 0.5-1.0) contained a reduced number silanol species attributed to either
33 adjacent silanol condensation or silica migration. However, complete removal
34 of aluminum was not obtained and only a fraction of the silanol defects were

1 healed. In contrast, Giudici, R., Kouwenhoven, H. W. and Prins, R. *Appl.*
2 *Catal. A*, 2000, 203, 101 reports that significant structural defects remained
3 after dealumination of mordenite with oxalic acid. de Ruiter, R., Pamin, K.,
4 Kentgens, A. P. M., Jansen, J. C. and van Bekkum, H. *Stud. Surf. Sci. Catal.*,
5 1994, 84, 2245 reports that high silica molecular sieves can be synthesized
6 from borosilicates by the deboronation of the materials at room temperature
7 with aqueous hydrochloric acid followed by subsequent insertion of silicon
8 species into the vacancies by treatment with tetramethylorthosilicate or
9 dichloromethylsilane in the liquid phase. This two-step procedure could give
10 partial silylation of the silanol nests to make a high-silica material with
11 relatively few defects (although high levels of repopulation were not
12 achieved). Single step treatments of the calcined borosilicate with SiCl_4 were
13 reported to give a substantial loss in crystallinity. In contrast, using the
14 method of the present invention, nearly complete removal of boron with
15 simultaneous healing of silanol nests by silicon is achieved in a single step
16 without the addition of any extra silica sources. Additionally, minor porosity
17 losses are incurred with this method.

18 Further investigations were carried out to probe the possibility of filling
19 the defect sites with species other than silicon. A fraction of the defects were
20 healed by aluminum or gallium using the following procedure: calcined SSZ-
21 33 was added to an aqueous solution of aluminum nitrate or gallium nitrate in
22 a plastic bottle and heated in an oven for 3 days at 95°C. Subsequently, the
23 solid was recovered by filtration and washed with 0.01 N HCl and water.
24 Using this technique, a portion of the defect sites are filled with the trivalent
25 cation and the remaining sites are left vacant, to give a metallosilicate with
26 internal defects when the amount of added Al or Ga is less than the total
27 number of silanol nests resulting from deboronation. For comparison,
28 calcined SSZ-33 was also treated with an equal amount of aluminum or
29 gallium in aqueous acetic acid and heated at 160°C for 6 days following the
30 acetic acid treatment procedure outlined here. After population of a portion of
31 the defect sites with the aluminum using the organic-free procedure, the ^{29}Si
32 BD NMR spectrum clearly shows the presence of both incorporated aluminum
33 and remaining silanols. The ^{29}Si CPMAS NMR spectrum shows a strong Q^3
34 silicon signal near -102 ppm and that the signal at -104 ppm in the BD

1 spectrum is attributable to $\text{Si}(\text{OSi})_3\text{OAl}$. The material contacted with acetic
 2 acid containing dissolved aluminum cations retains far fewer defect silanols
 3 than the material treated with the other insertion procedure. These results
 4 indicate that a large portion of the defect silanols can be healed while
 5 simultaneously inserting aluminum into a portion of the vacancies. Water
 6 adsorption data in Table 3 indicate that insertion in the presence of acetic acid
 7 results in a more hydrophobic aluminosilicate. The materials treated with
 8 acetic acid suffered from a minor loss in nitrogen capacity. ^{27}Al BD NMR
 9 results indicate that the aluminum in the samples is mostly tetrahedrally
 10 coordinated (tetrahedral peak at 57.9 ppm, octahedral peak at 0.4 ppm). The
 11 acetic acid treated material was found to contain less extraframework
 12 aluminum (~2%) than the material prepared using the other procedure
 13 (~10%). Similar results were obtained with the gallium treated materials.
 14 ^{71}Ga BD NMR spectra of both gallium-inserted samples have only a single
 15 resonance assigned to tetrahedral gallium at 166 ppm.

16 The results here indicate that the treatment is most effective at
 17 removing boron and healing the defects with silicon when the solution pH is
 18 slightly below the isoelectric point of silica (pH~ 2). Iler divides the behavior of
 19 aqueous silicates into 3 regions of pH: pH>7, 2<pH<7, and pH<2 (see Brinker,
 20 C. J. and Scherer, G. W. *Sol-Gel Science*, Academic Press: New York, 1990,
 21 p. 103 and Iler, R. K., *The Chemistry of Silica*, Wiley: New York, 1979). At
 22 pHs in excess of 7, condensation occurs by nucleophilic attack of OH^- . In the
 23 pH range of 2-7, the same mechanism is thought to occur, with the
 24 condensation rate proportional to the concentration of OH^- . In contrast, below
 25 a pH of 2, the rate is proportional to the concentration of H^+ (in the absence of
 26 F^-). It is under these conditions, where the solubility of silica is low (0<pH<2),
 27 that acid treatment is shown here to be very effective at producing nearly
 28 defect-free, pure silicates from borosilicates or zincosilicates without an
 29 external silicon source. At these conditions, the dissolution of the molecular
 30 sieve is slow enough to prevent significant loss of microstructure while at the
 31 same time allowing sufficient dissolution of silica to provide soluble species for
 32 healing of the defects.

33 The use the aqueous acetic acid treatment on molecular sieves was
 34 first used to extract TEAF from the pores of OFMSs and subsequently applied

1 to CIT-6 for a similar purpose. In both cases, it was found that extraction with
2 TEAF produced completely porous materials that were nearly free of
3 structural defects. In contrast, extraction of OFMSs with aqueous pyridine
4 ($\text{pH} > 7$) or a 50/50 mixture of pyridine and 1 N HCl ($\text{pH} = 5.65$), as well as
5 extraction of CIT-6 with 1 N NH_4NO_3 ($\text{pH} = 4.8$) gave porous materials that
6 contained internal structural defects. In light of the present invention, it is
7 clear that pH is an overriding factor that controls the presence or absence of
8 structural defects during extraction of SDAs or in the treatment of calcined
9 molecular sieves. Using the treatment in acidic media ($0 < \text{pH} < 2$), materials
10 that are nearly free of defects can be prepared from Si-Beta or OFMSs made
11 from TEAF, Si-Beta made using tetraethylammonium hydroxide (TEAOH),
12 and CIT-6 (zincosilicate beta) prepared with TEAOH. Similarly, we show here
13 that materials essentially free of defects can be synthesized from calcined
14 SSZ-33, B-Beta, CIT-1, and ERB-1 using similar treatments.

15 An equally important factor to pH is temperature. Moderate
16 temperatures (135°C) are required to expel boron from calcined B-Beta-F and
17 heal defects whereas higher temperatures leads to significant structural
18 degradation, possibly due to traces of residual F^- . For materials that contain
19 no F^- , such as ERB-1, SSZ-33 or CIT-1 (molecular sieves that were
20 synthesized in hydroxide media) higher temperatures give better results (160 -
21 185°C) with limited loss in porosity due to structural degradation. Hence,
22 calcined samples synthesized in the presence of F^- require lower
23 temperatures for effective healing of defects with silicon.

24

25

EXAMPLES

26

27 The materials shown in the tables below were treated using the acids
28 and conditions shown in the tables.

1
2
3

Table 1
Synthetic and physical parameters of samples

Sample	Topology ^a	Treatment	pH ^b	Temp. (C)	Time	Si/B ^c	N ₂ ads (cc/g) ^d	H ₂ O ads. (cc/g) ^e
CIT-1	CON	None	-----	-----	-----	20.9	0.225	0.034
CIT-1	CON	aq. acetic acid	1.65	160	6 days	>20 00	0.244	0.013
CIT-1	CON	aq. acetic acid	1.65	185	6 days	ND	0.209	0.006
SSZ-33	CON	None	-----	-----	-----	19.4	0.181	0.063
SSZ-33	CON	aq. HCl	2.00	25	5 hours	ND	0.173	0.055
SSZ-33	CON	aq. acetic acid	1.65	110	6 days	156. 5	0.186	0.020
SSZ-33	CON	aq. acetic acid	1.65	135	6 days	ND	0.186	0.017
SSZ-33	CON	aq. acetic acid	1.65	160	6 days	ND	0.184	0.015
SSZ-33	CON	aq. acetic acid	1.65	185	6 days	494. 0	0.175	0.006
SSZ-33	CON	aq. acetic acid	1.65	135	14 days	ND	0.173	0.009
ERB-1	MWW	None	-----	-----	-----	10.9	0.165	0.045
ERB-1	MWW	aq. HCl	2.00	25	5	36.5	0.159	0.087

10032270-122004

					hours			
ERB-1	MWW	aq. acetic acid	1.65	135	6 days	75.0	0.170	0.036
ERB-1	MWW	aq. acetic acid	1.65	160	6 days	ND	0.164	0.013
ERB-1	MWW	aq. acetic acid	1.65	185	6 days	ND	0.146	0.007
ERB-1	MWW	aq. acetic acid	1.65	185	6 days	ND	0.141	0.011
Si-MFI	MFI	None	----	----	----	----	0.144	0.011
Si-MFI	MFI	aq. acetic acid	1.65	185	6 days	----	0.153	0.013
B-MFI	MFI	None	----	----	----	51.4	0.138	0.019
B-MFI	MFI	aq. acetic acid	1.65	135	6 days	>90 0	0.143	0.013
B-MFI	MFI	aq. acetic acid	1.65	185	6 days	>40 0	0.140	0.009
Si-Beta- OH	*BEA	None	----	----	----	----	0.285	0.045
Si-Beta- OH	*BEA	aq. acetic acid	1.65	135	6 days	----	0.248	0.047
Si-Beta- OH	*BEA	aq. acetic acid	1.65	160	6 days	----	0.226	0.030
B-Beta-	*BEA	None	----	----	----	29.2	0.231	0.039

F								
B-Beta-F	*BEA	aq. acetic acid	1.65	135	6 days	>35 0	0.239	0.039
B-Beta-F	*BEA	aq. acetic acid	1.65	185	6 days	>10 00	0.099 ^f	0.011

a) international zeolite association

structure code

b) initial solution

pH

c) Si/B ratio as determined

by elemental analysis

d) as determined by nitrogen

adsorption, 77°C P/Po = 0.05

e) water adsorption on a McBain-Bakr

balance, 25°C, P/Po = 0.2

f) some structural collapse

ND = not

determined

- 1 It should be noted that when the material was treated at 25° C., the defects in
- 2 the material's crystal structure were not annealed (repaired).

3

4

Table 2

5

Assignment of ²⁹Si BD NMR lines of CIT-1 extracted at 185°C.

6

300 Mhz ^a	500 MHz ^b	300 Mhz ^a	500 MHz ^b	300 Mhz ^a	500 MHz ^b
d ^c	d ^c	l ^d	l ^d	FWHM ^e	FWHM ^e
-109.49	-109.61	1.1	1.1	0.635	0.515
-109.93	-109.98	1.1	1.0	0.948	0.870
-111.16	-111.03	1.3	1.2	0.736	0.600

-111.5	-111.53	1.3	1.0	0.441	0.358
-112.2	-112.15	0.9	0.7	0.489	0.302
-113.2	-113.22	0.9	1.0	0.389	0.338
-116.45	-116.49	0.8	0.9	0.482	0.311

a) 10s pulse delay

b) 60s pulse delay

c) chemical shift, in ppm

d) intensity, (normalized; crystal structure predicts all should have intensity=1)

e) full width half max

Table 3

Synthetic and physical parameters of samples used in control experiments

Sample	Topology ^a	Treatment	PH ^b	Temp. (C)	Time	Si/B ^c	N ₂ ads (cc/g) ^d	H ₂ O ads. (cc/g) ^e
<i>Varying the acid</i>								
SSZ-33	CON	aq. acetic acid	1.65	135	6 days	ND	0.186	0.017
SSZ-33	CON	aq. HCl	1.30	135	6 days	ND	0.178	0.016
SSZ-33	CON	aq. HNO ₃	1.30	135	6 days	ND	0.168	0.014
SSZ-33	CON	aq. H ₂ SO ₄	1.30	135	7 days	ND	0.170	0.020
<i>Varying the pH and temperature</i>								
SSZ-33	CON	aq. acetic acid	0.75	135	6 days	196.0	0.186	0.028
SSZ-33	CON	aq. acetic acid	1.65	135	6 days	ND	0.186	0.017
SSZ-33	CON	aq. acetic acid	2.50	135	6 days	66.9	0.154	0.027
SSZ-33	CON	aq. acetic acid	0.90	185	6 days	ND	0.193	0.004
SSZ-33	CON	aq. acetic acid	1.65	185	6 days	494.0	0.175	0.006
SSZ-33	CON	aq. acetic acid	2.50	185	6 days	ND	0.076	ND
<i>Additional Iterations</i>								
SSZ-33	CON	water, Al(NO ₃) ₃	ND	95	3 days	56.7 ¹⁹ (199)	0.186	0.065
SSZ-33	CON	aq. acetic acid,	1.65	160	6 days	56.3 ⁹	0.175	0.059

		Al(NO ₃) ₃						
SSZ-33	CON	water, Ga(NO ₃) ₃	ND	95	3 days	45.1 ^h	0.189	ND
SSZ-33	CON	aq. acetic acid, Ga(NO ₃) ₃	1.65	160	6 days	78.1 ^h	0.175	ND
SSZ-33	CON	aq. acetic acid ⁱ	1.65	135	6 days	ND	0.167	0.009
SSZ-33	CON	aq. acetic acid ^j	1.65	135	6 days	ND	amor. ^k	ND
ERB-1	MWW	aq. acetic acid ⁱ	1.65	185	6 days	ND	0.141	0.011

a) international zeolite association
structure code

b) initial solution pH

c) Si/B ratio as determined by elemental
analysis

d) as determined by nitrogen adsorption
P/Po = 0.05

e) water adsorption on a McBain-Bakr balance,
25°C, P/Po = 0.2

f) Si/B ratio in parentheses after
treatment

g) Si/Al ratio as determined by elemental
analysis

h) Si/Ga ratio as determined by elemental
analysis

i) solution pre-saturated with soluble SiO₂
species

j) solution pre-saturated with soluble
GeO₂ species

k) structural collapse leaving nonporous,
amorphous material

ND = not

determined